

01/07/02
10040646
Jest
64

BEST AVAILABLE COPY
U.S. UTILITY Patent Application

PATENT NUMBER and
ISSUE DATE

APPL NUM 10040646	FILING DATE 01/07/2002	CLASS 216	SUBCLASS 24	GAU 1746	EXAMINER Alan Ko
**APPLICANTS: Nishiki Hirohiko; Atkinson James; Nakata Yukihiko;					
**CONTINUING DATA VERIFIED:					
** FOREIGN APPLICATIONS VERIFIED:					
PG-PUB <input type="checkbox"/> DO NOT PUBLISH <input type="checkbox"/>		RESCIND <input type="checkbox"/>			
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no				ATTORNEY DOCKET NO	
35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no				SLA 0452	
Verified and Acknowledged Examiners's initials					
TITLE : System and method for etching resin with an ozone wet etching process					

U S DEPT OF COMM /PAT & TM-PTO-436L/Rev 12-94

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs.Drwg. Print Fig.
<input type="checkbox"/> TERMINAL DISCLAIMER		Application Examiner	
		PREPARED FOR ISSUE	
WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368, Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.			

FILED WITH: ☐ DISK (CRF) ☐ CD-ROM
(Attached in pocket on right inside flap)